

Receipt date: 03/16/2009

OK TO ENTER: /M.L.P./

03/22/2009

**RESPONSE UNDER 37 C.F.R. §1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1792**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Choe et al.

Examiner: Padgett, Marianne L.

Serial No.: 10/674,648

Art Unit: 1792

Filed: September 30, 2003

Docket No.: YOR920030294US1 (16817)

Title: SOI BY OXIDATION OF
POROUS SILICON

Date: March 16, 2009

Confirmation No.: 4794

Commissioner for Patents
P.O. Box 1450
Alexandria, VA. 22313

RESPONSE UNDER 37 C.F.R. § 1.116


Sir:

In response to the Final Office Action dated January 16, 2009, Applicants respectfully request that the following amendments and remarks be entered as a matter of record in the above-identified application. Also included herein is an Examiner Interview Summary of the phone interview between Examiner Marianne L. Padgett and Applicants' representative held on March 16, 2009.

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on March 16, 2009.

Dated: March 16, 2009


Harry A. Hild Jr